

# Introduction for **FOLP**® Technology

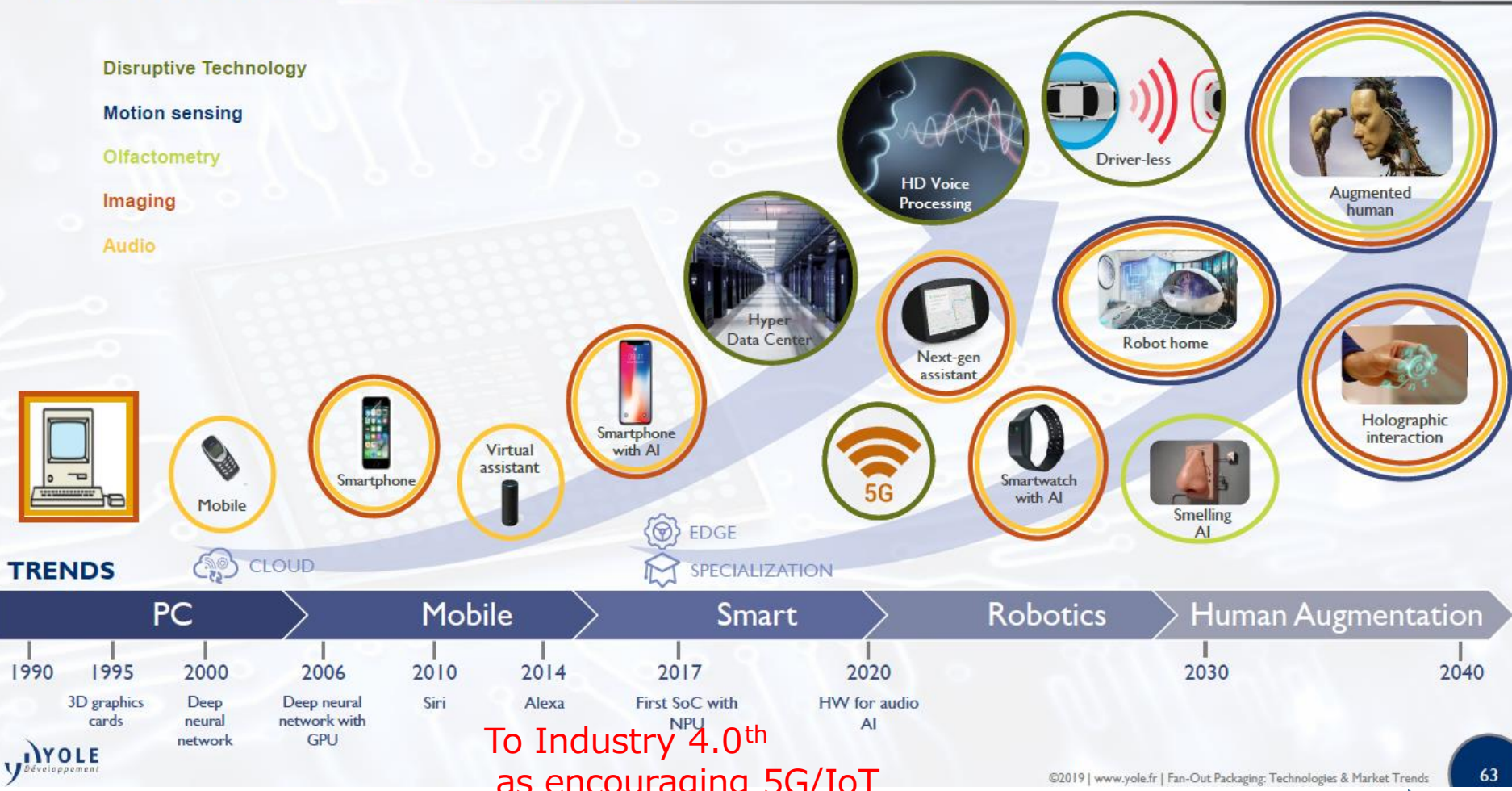
**FOLP**® (*Fan-Out Leaded Package*)/ FOPLP



# Development background

# Technical Packaging trend for Applications

## MEGA TRENDS OF ELECTRONICS



To Industry 4.0<sup>th</sup>  
as encouraging 5G/IoT

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63

1990  
CSP/BGA SiP  
Technology

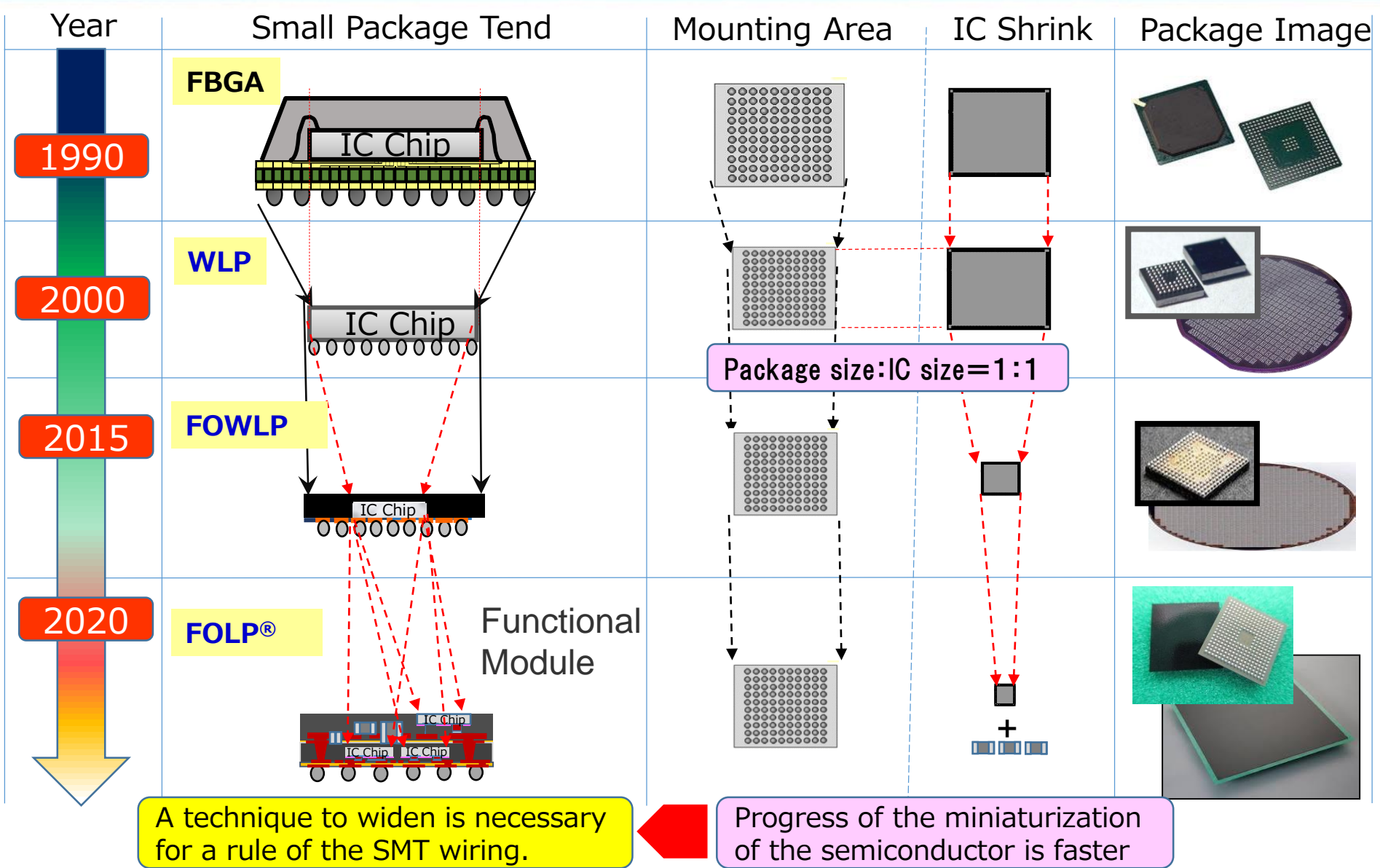
2000  
WLP/FCBGA/POP  
Technology

2010  
FO-WLP/3D/TSV/Cu Pillar /  
Si interposer Technology

2020~.  
3 D Integrated **FOPLP** Technology

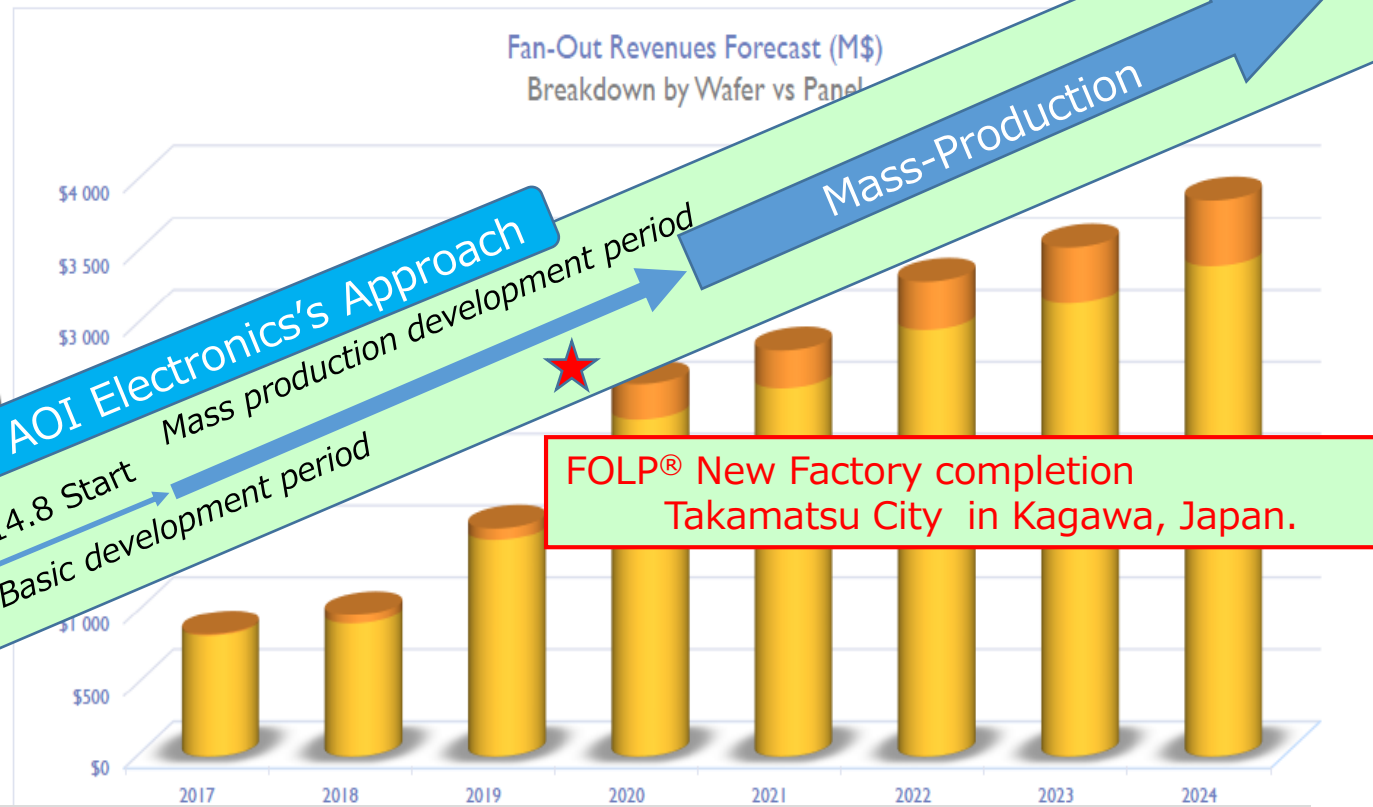


# BGA Package miniaturization trend for mobile·IoT/5G



# FOLP® Development History

Wafer-Level will still be dominant in market. Panel is expected to gain more market share in 2020.

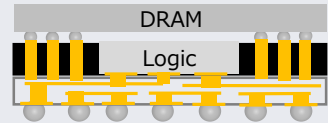
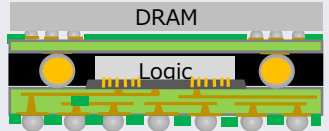


FOLP® New Factory completion  
Takamatsu City in Kagawa, Japan.

History	
Aug/2014	Joint Development with 2 overseas OSAT.
Aug/2017	FOLP® development switched from Wafer type to Panel type.
Jul/2019	New Factory was built at Takamatsu city in Kagawa, Japan.
2021	FOLP® is planning to start Mass-production soon.



# AOI Target's application and specification

	Level 1	Level 2	Level 3
Application	RF , PMIC. MEMS , Sensor	BB Combo , Single-Chip High-end	APE , SiP
L/S Rule Target	(L/S:20/20-15/15)	(L/S:10/10um)	(Under L/S:5/5um )
Cu Pillar Pitch	80~200um	40~80um	Less than 40um
Example of Current PKG (Smart Phone)	RF: Front End module RF: Power amp module RF: Wi-Fi BT GPS module RF: Antenna SW module RF:RF Transceiver PMIC Electric Compass Accelerometer Gyroscope NFC	Baseband Processor APP PMIC	POP  
Expect Specification of FOPLP	Size:2-6mm sq. 1chip:compass,P.M. 1Layer 2chip:Another 1-2Layer	Size:6-10mm sq. 1chip:P.M. , APP 1Layer 2chip:BB combo 1-2Layer	Size:10-20mm sq. APP&DRAM 2chip side by side SIP 2Layer

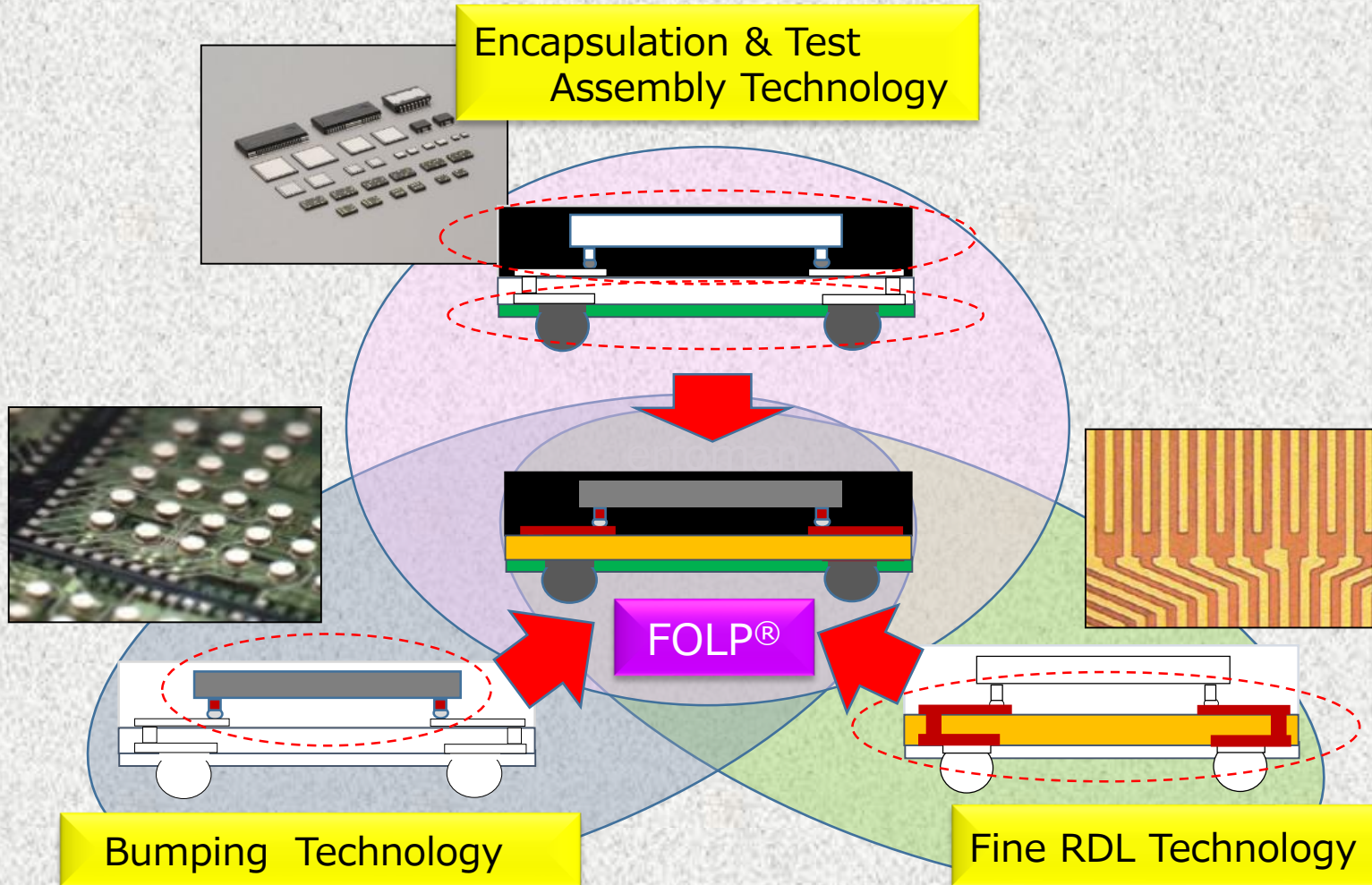
1<sup>ST</sup> Target

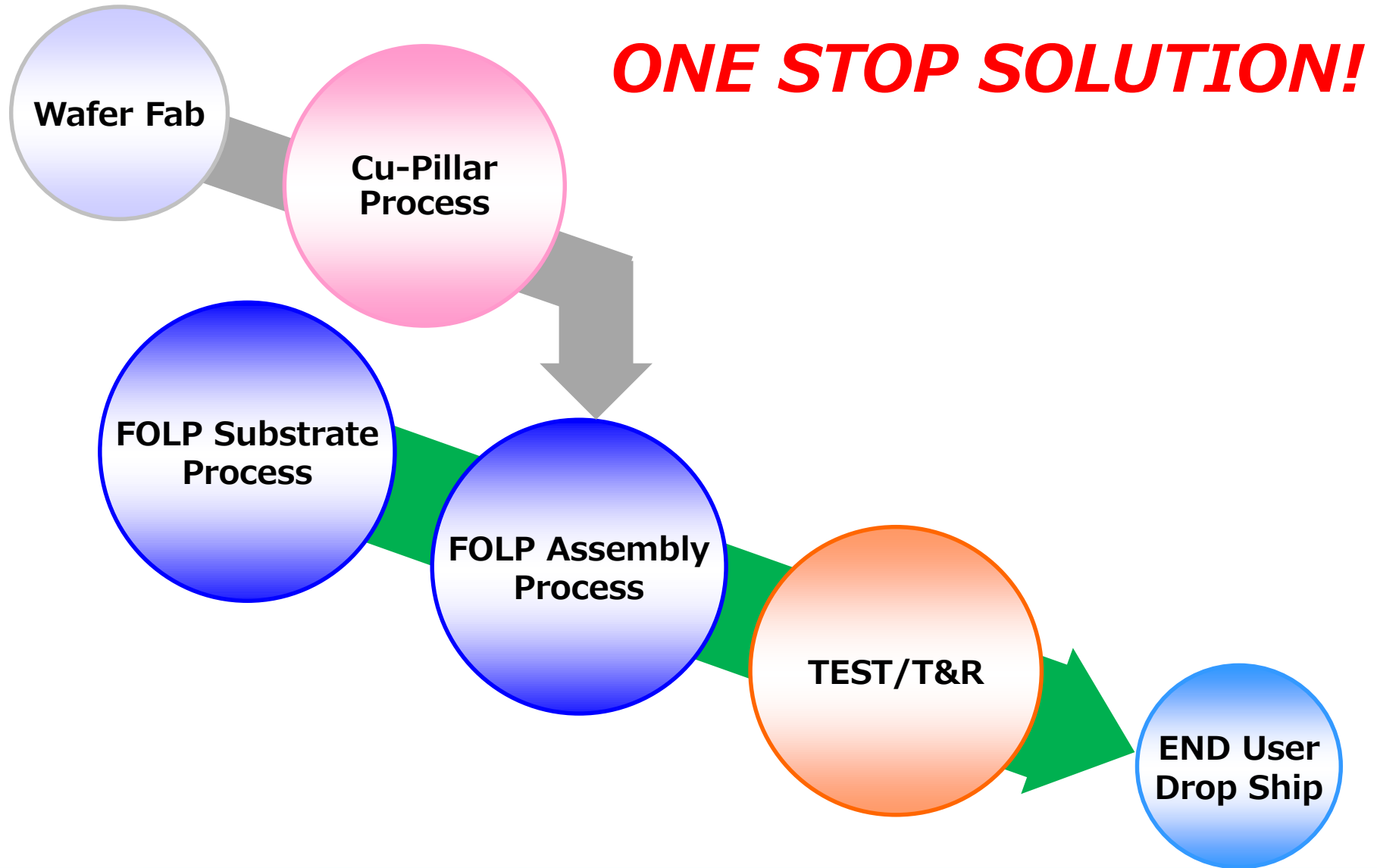


Next Stage Target



# AOI Group Package Technology

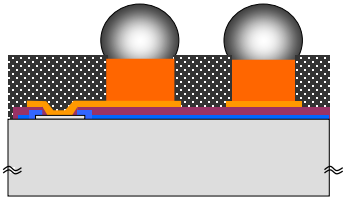




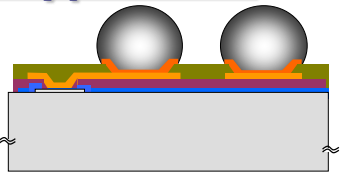


# Types of WLP and Bumping new development

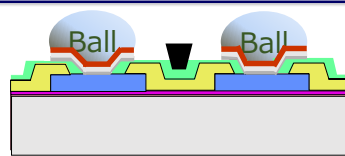
## Cu Post WLP



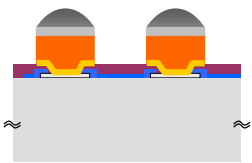
## U type WLP



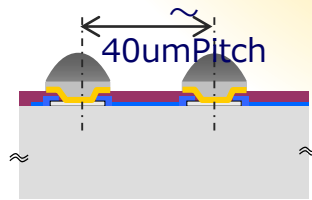
## With Solder ball



## Cu Pillar

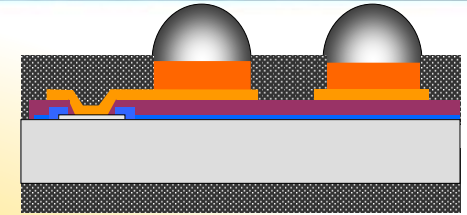


## Micro Bump (Solder)

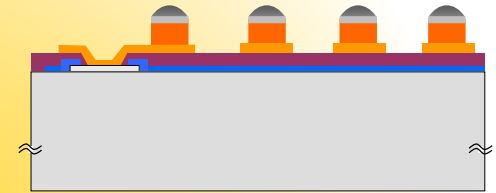


## Developing new technology

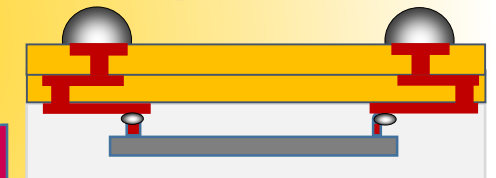
- Improving WLP reliability
- Cu pillar technology
- FOLP® technology
- N in 1 Module technology etc.



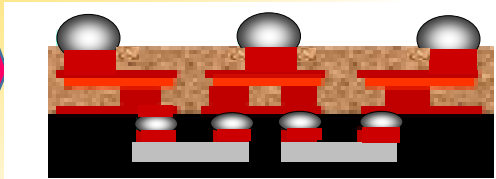
## Improving WLP reliability



## Fine pitch Cu Pillar



## FOLP® (FOPLP/Chip Last)

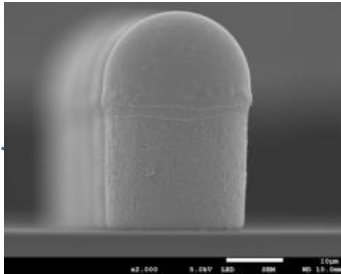
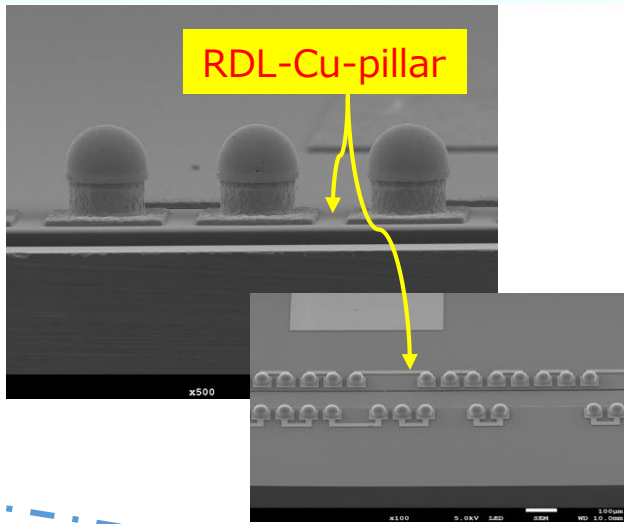
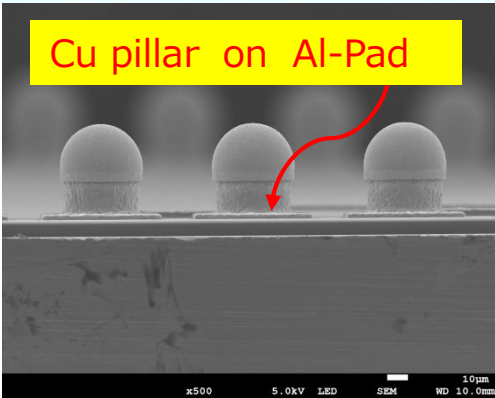
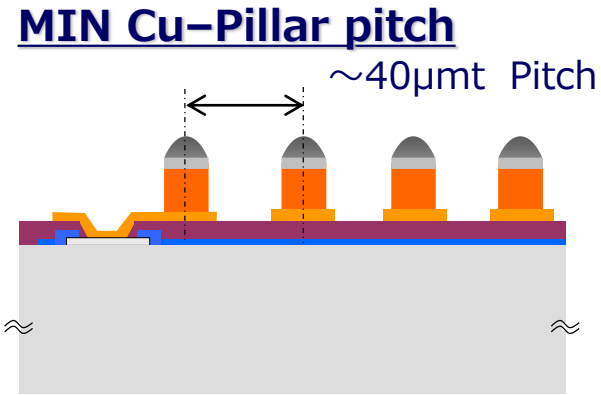


## N in 1 (FOLP® module)

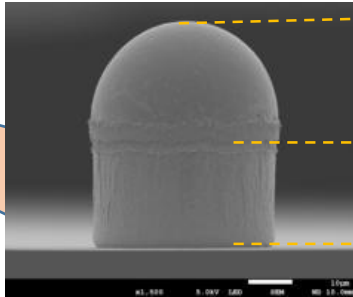
# Cu-Pillar Variation

[ $\mu\text{m}$ ]

	Current
Wafer Size	6,8&12 inch
Aspect	2.5
MIN Diameter	20
MAX Height	50
Terminal structure	SnAg/Ni/Cu SnAg/Cu

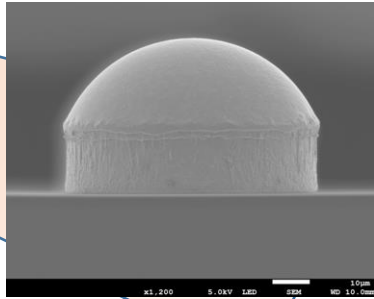


$\Phi 25 \times t40$



$\Phi 45 \times t50$

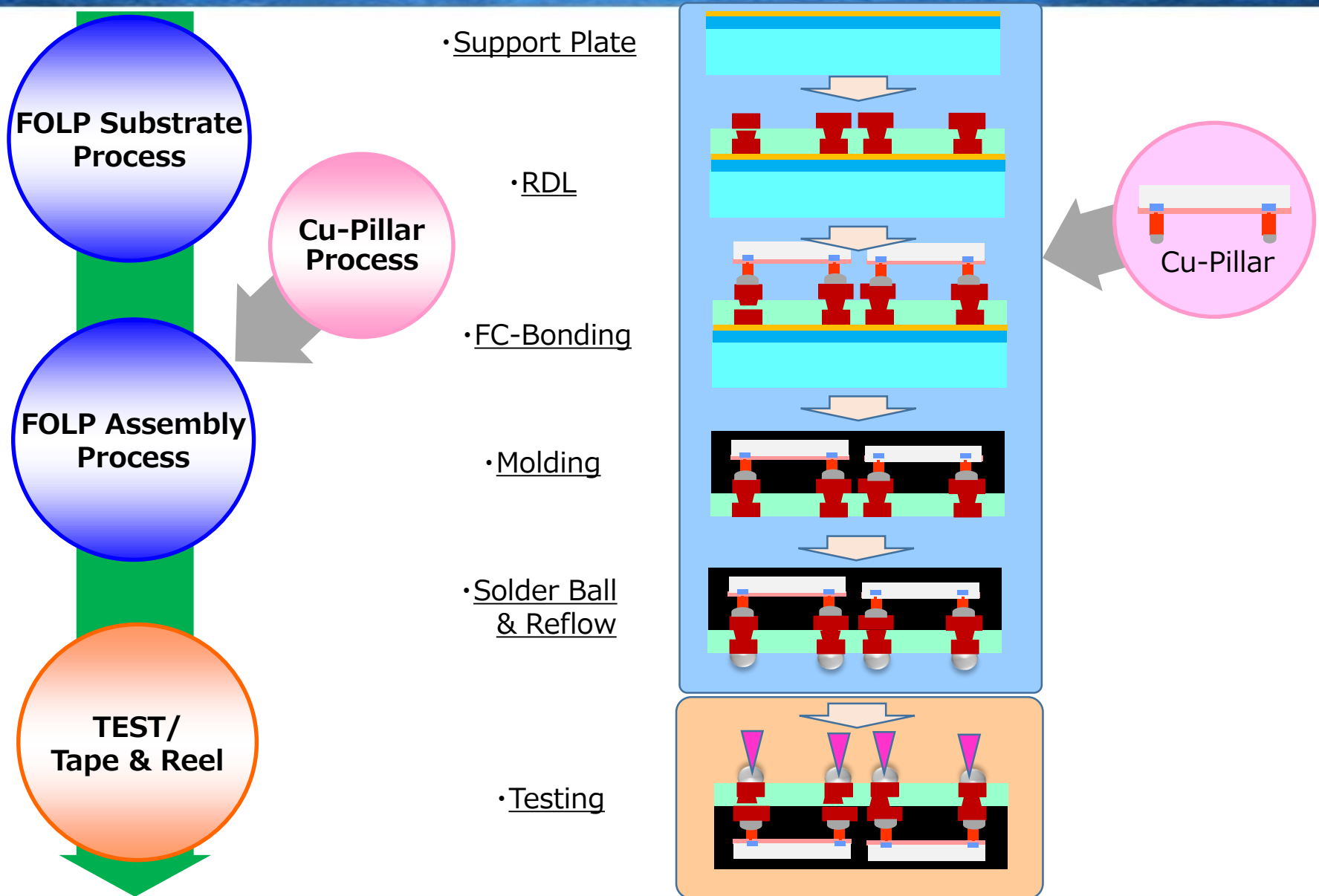
Aspect  $a : b \cong 1 : 1$



$\Phi 70 \times t45$

AOI Electronics's Cu-pillar bumping are well-known for their reliability due to its long history of achievements from 2006y.

# FOLP® (FOWLP) Process Flow (RDL First Method)



# FOLP<sup>®</sup> Process Merit & AOI's Advantage

1.High Yield : KGD +KG Substrate Combination

2.Short cycle time : Horizontal specialization Process

\*Wafer Bumping

\*Substrate(RDL) Process

\*Assembly +TEST/Tape & Reel Process

3.One stop solution in AOI-ELECTRONICS Group.

4.High reliability : -Modified Epoxy resin  
-Solder materials of various composition attach

5.High performance :AOI can use the Low Dk,Df substrate materials  
for RF 5G devices.

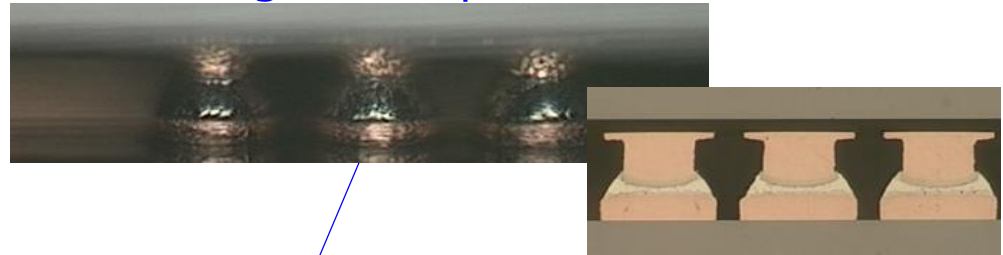


# Example of application for FOLP®

# FOLP® Elemental Technology (1)

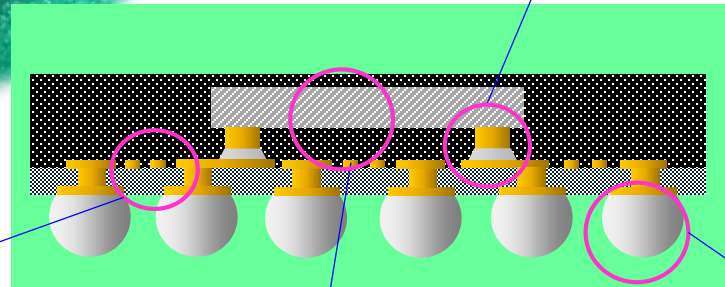
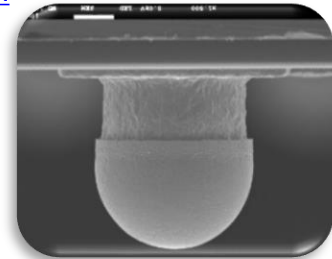
## Basic Model

### C4 bonding & encapsulation



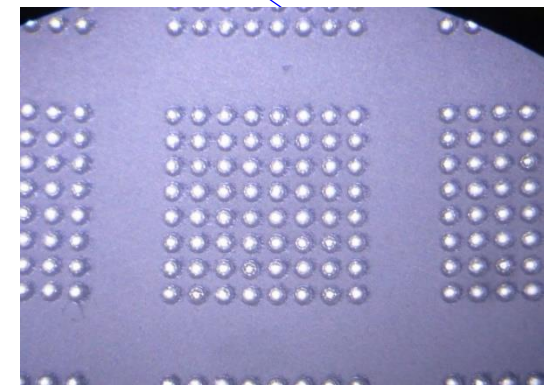
### Cu Pillar Bump

~40µm Pitch



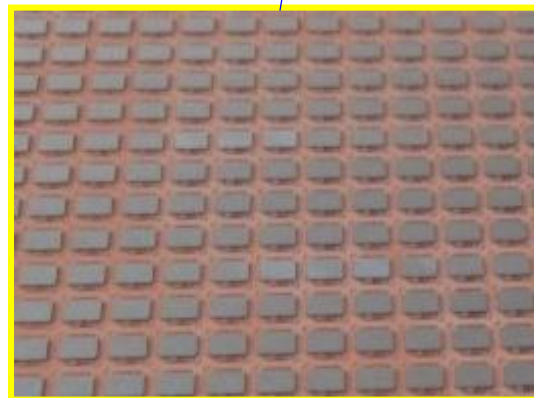
### Solder Bump

SAC, SACN, SACNBI Others



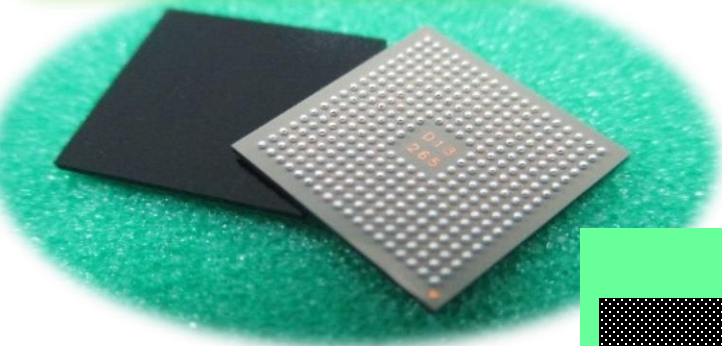
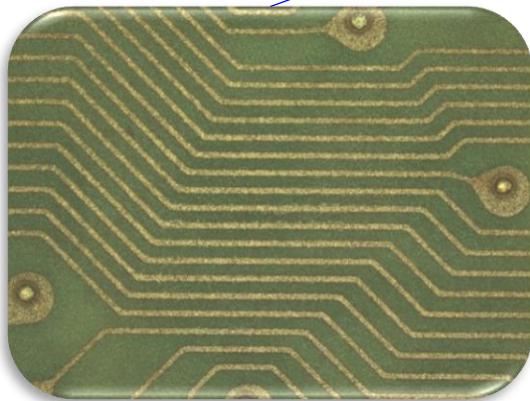
### FC-Bonding

Si, SiGe, GaN, GaAs Others (100µm)



### Fine Pitch RDL

(Line=10µm)



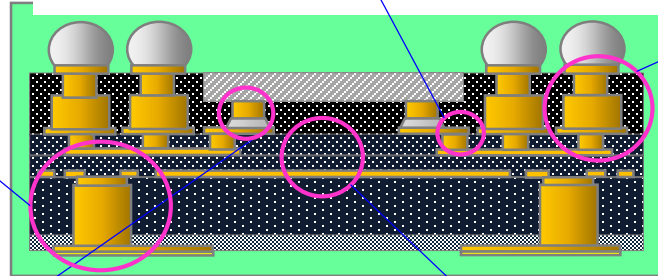
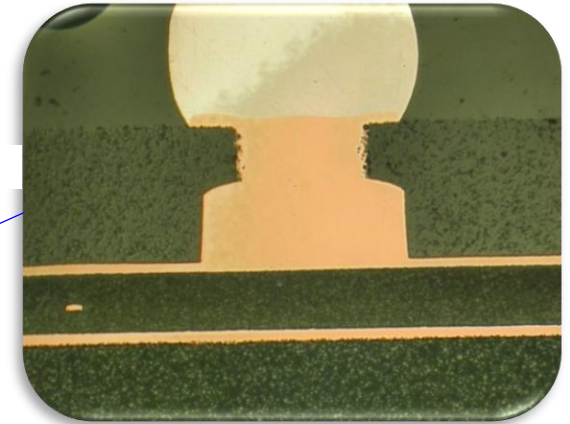
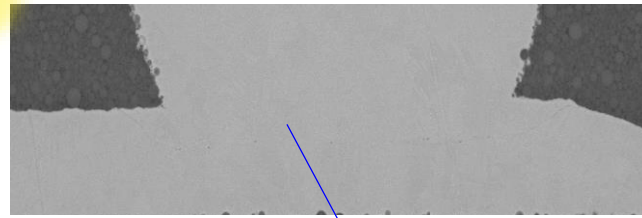
## Applied Model

AiP Case

Detail of Via bottom

New Through Via Type②  
ToM(Terminal on Mold)

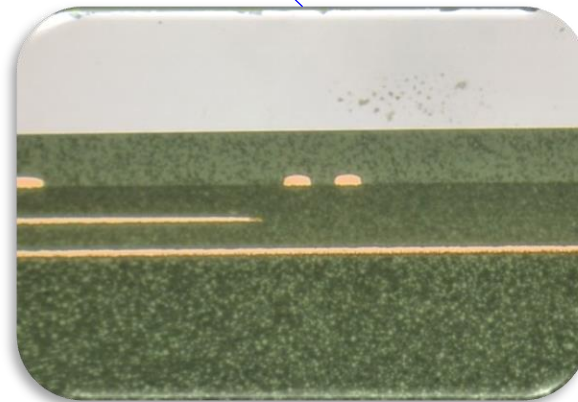
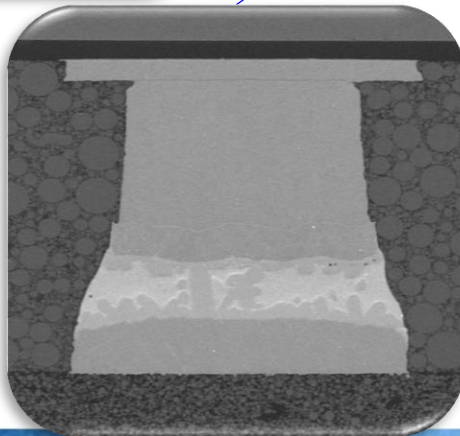
New Through Via Type①



Backside Grinding

No capillary underfill

C4 bonding

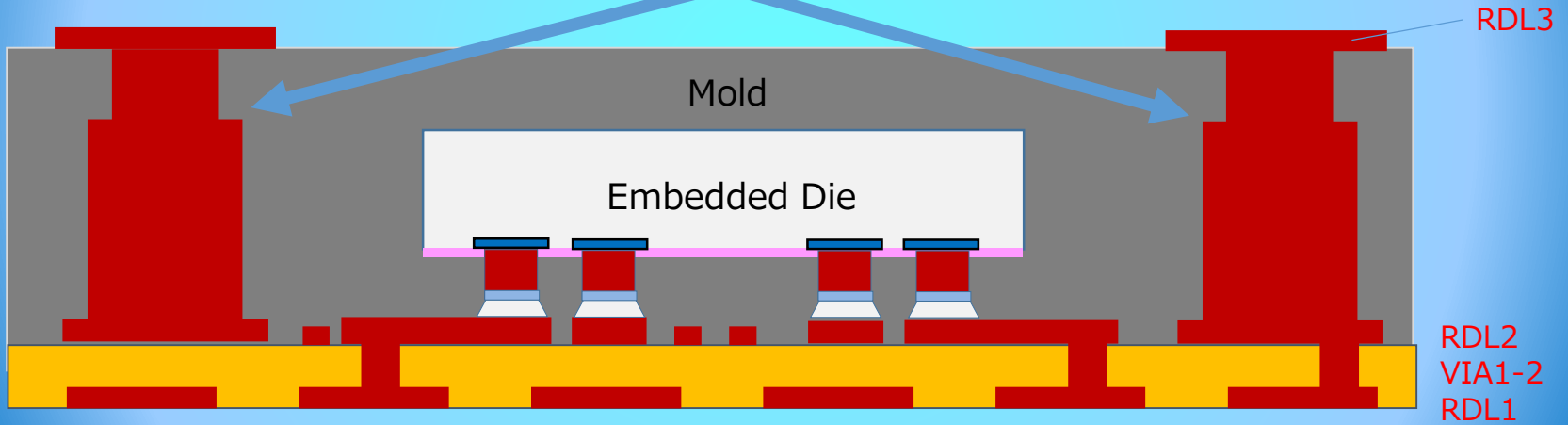




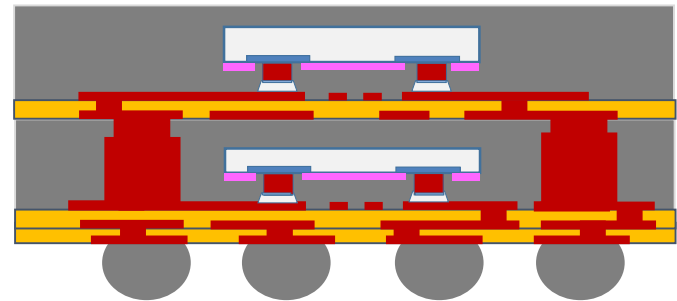
# Stacked FOLP®

## Through Via Type

### New Through Via structure



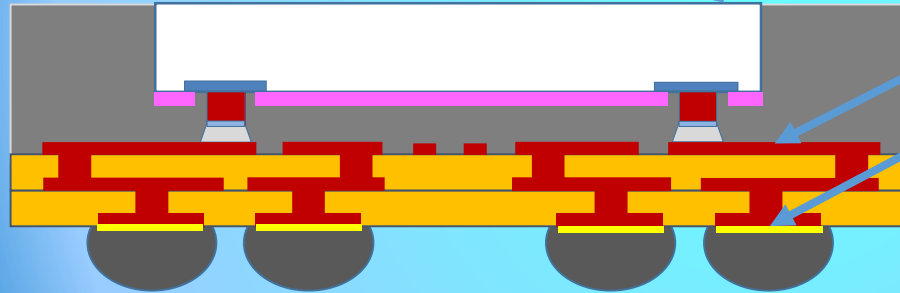
## Stacked FOLP®





# Active + Passive Device FOLP® Module

## Heat dissipation structure



Backside grinding exposure

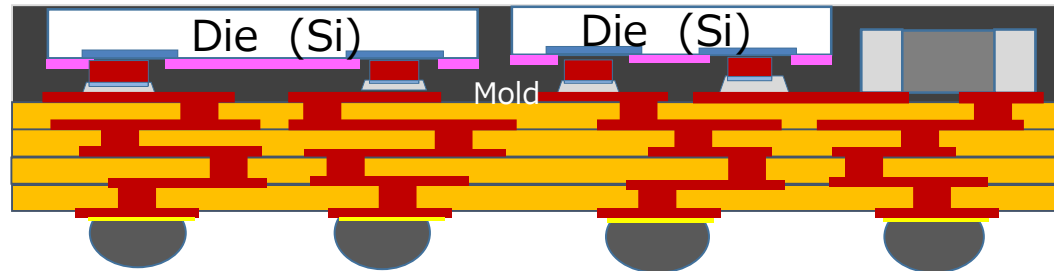
Multi-layer RDL

Solder Ball on Au-Pad

## Thinner FOLP®

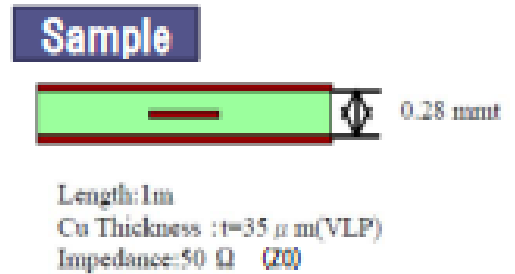
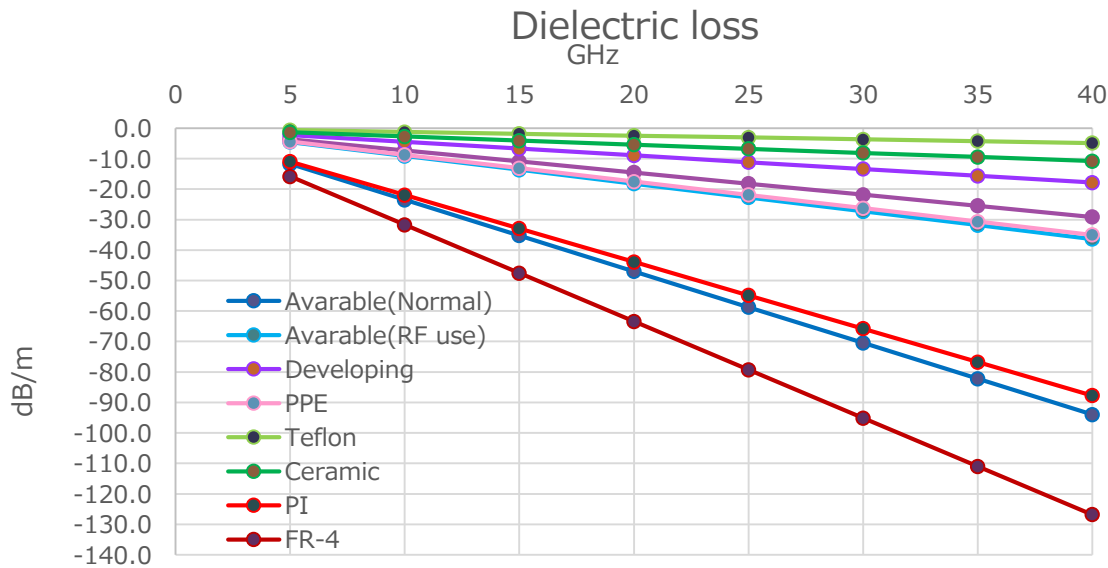


Possible to form five RDL layers



RDL5 (L5)  
RDL4 (L4)  
RDL3 (L3)  
RDL2 (L2)  
RDL1 (L1)

# FOLP<sup>®</sup> Isolation Materials for RF devices



Type	Film thickness	Dk			Df			Breakdown Strength (kV/mm)
		20GHz	40GHz	60GHz	20GHz	40GHz	60GHz	
Normal	35umt (Typical)	2.2	2.2	2.2	0.0151	0.0151	0.0151	15.1
Thick film	~200umt							
Low stress	35umt (Typical)							
RF	35umt (Typical)							
Developing	35umt (Typical)	3.1	3.1	3.1	0.0011	0.0030	0.0031	15.1

Please feel free to contact us about the isolation material characteristics.

# Technology Roadmap





# Reliability

# Reliability results

## FOLP® SPEC.

### 【FOLP®】

Size :4.1mmSQ  
Terminal Pitch :0.4mm  
Height :0.7mm  
I/O count :64pin

### 【Si Chip】

Chip Size :2.1×3.0mm  
Cu Pillar :Pitch :75μm  
Diameter :40μmΦ

Items	Condition	N count	Result
MSL Level 1	85°C/85% 168hr ⇒260°C 30sec 3 times	22	No fail
PCT (PKG)	Pre-condition ⇒121°C 100% 500cyc	22	No fail
HTHH (PKG)	Pre-condition ⇒85°C 85%RH 1000hr	22	No fail
HTS (PKG)	Pre-condition ⇒150°C 168hr , 500hr , 1000hr	22	No fail
TCT (PKG)	Pre-condition(each 15min/RT2min) ⇒-65°C~RT~150°C 1000cyc	22	No fail
Drop Test (Board)	JEDEC 【JESD22-B111】 1500G time : 0.5msec	2	MTTF 546 times 1 <sup>ST</sup> Fail 76 times  Pass/Fail :30 times

# AOI-ELECTRONICS's FOLP<sup>®</sup> supports IoT Technologies



**Monitoring system**



**Energy**



**Industrial Engineering**



**Smart City**



**FOLP<sup>®</sup>**

### **IoT/M2M Communication module**

LTE / 5G / WiMAX / Z-Wave / ZigBee / Bluetooth / RFID  
NFC / Transfer Jet / Felica / PLC / Tuner / GPS /

### **Sensor / MEMS Device**

CIS / Compass / Tunable capacitor

### **Analog / Power / Driver / RF / Memory ICs**

PMIC / RF / BaseBand / Switch / Converter / Battery  
Control / Flash / DRAM / OLED control SoC / Others

### **Automotive ICs**

Radar system / RF tuner for Navigation systems



**Home automation**



**Transportation**



**infrastructure**



**Medical Health care**

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